EEE-2103: Electronic Devices and Circuits

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Transistor Construction

Transistor \rightarrow

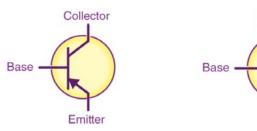
three-layer semiconductor device pnp = two p - and one n -type layers npn = two n - and one p -type layers E = emitter, C = collector, E = base

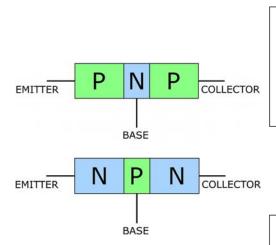
emitter layer is heavily doped, base and collector are lightly doped

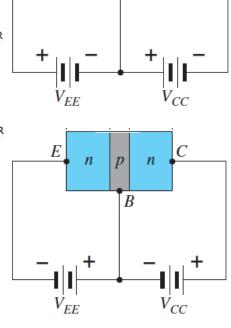
total width: center layer = 150:1

sandwiched layer doping : outer layers doping <= 1:10

BJT = bipolar junction transistor bipolar = both holes and electrons participate in injection process







Transistor Operation

One p-n junction is reverse-biased Another p-n junction is forward-biased.

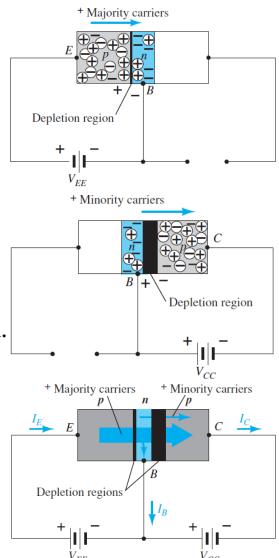
Large number of majority carriers diffuse across forward biased p-n junction into n-type material.

Sandwiched n-type material is very thin and has low conductivity. very small number of majority carriers \rightarrow base terminal.

For reverse-biased junction →

injected majority carriers = minority carriers in n-type base region. Larger number of majority carriers + all minority carriers in depletion region \rightarrow diffuse across reverse-biased junction into p-type.

 $I_B \approx$ microamperes, $I_E \approx$ milliamperes.



Transistor Operation

Applying Kirchhoff's current law

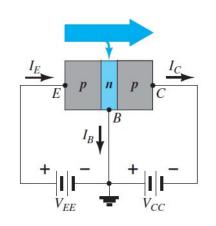
$$I_E = I_C + I_B$$

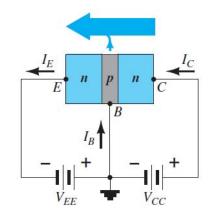
Collector current = majority + minority carriers Minority-current component = I_{CO} = leakage current I_{CO} = I_{C} current with emitter terminal Open

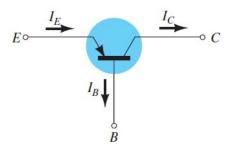
$$I_C = I_{C majority} + I_{C O minority}$$

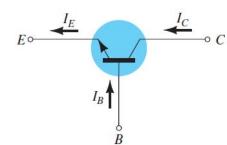
 $I_C \approx \text{milliamperes}$ $I_{CO} \approx \text{microamperes}$ or nanoamperes

 $I_B \approx$ microamperes, $I_E \approx$ milliamperes.









Common-base terminology →

base is common to both input and output base is closest to, or at, ground potential.

$$I_E = I_C + I_B$$

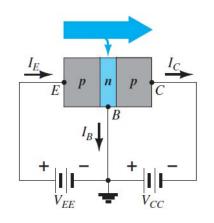
biasing voltage sources establish current such that

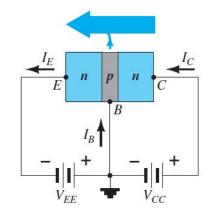
$$V_{EE} \rightarrow \text{direction of } I_E$$

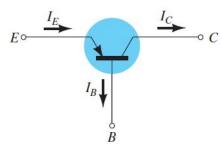
$$V_{CC} \rightarrow \text{direction of } I_C$$

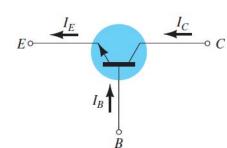
Two sets of characteristics \rightarrow

- i) driving point or input parameters
- ii) output side.

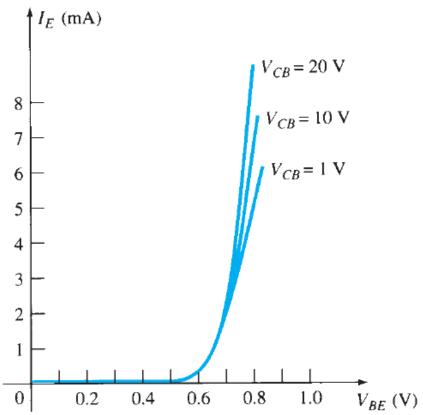


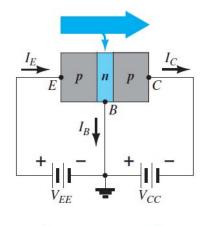


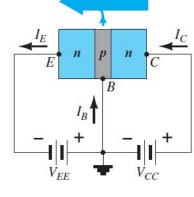


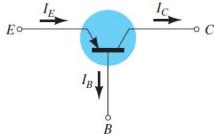


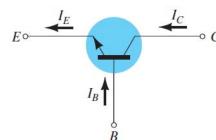
Input set for CB configuration \rightarrow input current (I_E) to input voltage (V_{BE}) various levels of output voltage (V_{CB})









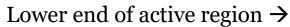


Output set for CB configuration \rightarrow output current (I_C) to output voltage (V_{CB}) various levels of input current (I_E)

↓ *I_C* (mA) Three basic regions of interest \rightarrow active, cutoff, and saturation Active region (unshaded area) 6 mA 5 mA Saturation region 4 mA 3 mA 2 mA $I_E = 1 \text{ mA}$ $I_{CO} = I_{CBO}$ $I_E = 0 \text{ mA}$ $V_{CB}(V)$ 10 20 30 BV_{CBO} Cutoff region

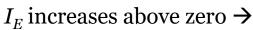
Active region \rightarrow

base-emitter junction is forward-biased collector-base junction is reverse-biased.



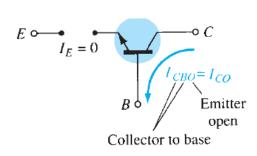
$$I_E = 0$$
, $I_C = I_{CO} = microamperes$

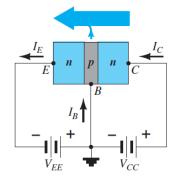
 $I_{CO} = I_{CBO} = \text{collector-to-base current }$ emitter leg open

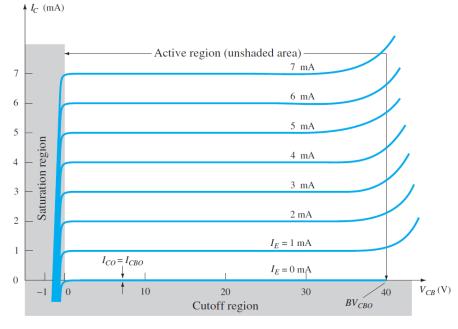


$$I_{C} \approx I_{E}$$

effect of V_{CB} is negligible.







Cutoff region \rightarrow

base-emitter and collector-base junctions are both reverse-biased.

$$I_C = 0$$

Saturation region \rightarrow

base-emitter and collector-base junctions are forward-biased.

